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## Group VI Heteroatomcyclopolsilanes Syntheses and NMR Properties

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# GROUP VI HETEROATOMCYCLOPOLYSILANES SYNTHESSES AND NMR PROPERTIES

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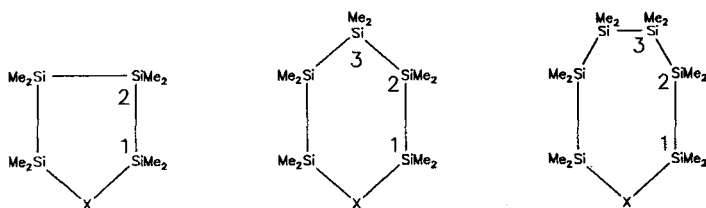
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**Abstract** Group VI heterocyclopolsilanes have been synthesized from  $\alpha,\omega$ -dichloropolysilanes and  $\text{Li}_2\text{S}/\text{Li}_2\text{Se}$  or by simple hydrolysis. Si-Si NMR coupling constants correlate satisfactorily with electronegativities of the heteroelements indicating dominant Fermi contact contributions.

## INTRODUCTION

Just one systematic study dealing with permethylheterocyclopolsilanes has been published so far by West and coworkers<sup>1</sup>. Because we are generally interested in Si-Si bond/substituent interactions, we decided to attempt the selective synthesis of group VI heterocyclopolsilanes exhibiting structural formulae as depicted below and to investigate their spectral properties.

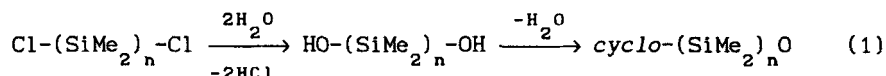


X = O, S, Se

[207]/29

SYNTHESES

The oxygen containing heterocycles are readily formed after careful hydrolysis of the corresponding  $\alpha,\omega$ -dichlorooligosilanes followed by condensation of the  $\alpha,\omega$ -diol intermediates:



The sulfur and selenium derivatives are easily obtained, when the  $\alpha,\omega$ -dichloroprecursors are reacted with  $\text{Li}_2\text{S}$  or  $\text{Li}_2\text{Se}$  prepared in situ from S or Se and  $\text{Li}[(\text{BEt}_3)\text{H}]$  in  $\text{THF}^2$ :

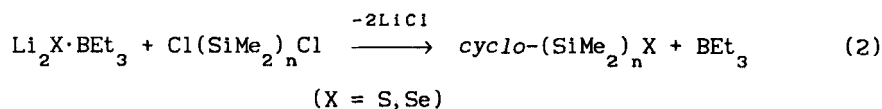


TABLE 1 Si-Si coupling constants in [Hz] obtained by the INEPT-INADEQUATE technique and  $^{29}\text{Si}$  chemical shifts in [ppm] relative to TMS of permethylheterocyclooligosilanes

	$^1J_{\text{Si1Si2}}$	$^1J_{\text{Si2Si3}}$	$^2J_{\text{Si1Si3}}$	$\delta \text{ Si1}$	$\delta \text{ Si2}$	$\delta \text{ Si3}$
$\text{Si}_4\text{Me}_8\text{O}$	81.27	-	10.6	14.84	-	-50.4
$\text{Si}_5\text{Me}_{10}\text{O}$	83.96	58.29	7.2	9.74	-49.6	-45.8
$\text{Si}_6\text{Me}_{12}\text{O}$	88.07	60.58	7.4	8.32	-47.1	-42.4
$\text{Si}_4\text{Me}_8\text{S}$	75.85	-	13.0	9.24	-	-44.2
$\text{Si}_5\text{Me}_{10}\text{S}$	76.06	61.74	8.17	1.99	-44.9	-43.8
$\text{Si}_6\text{Me}_{12}\text{S}$	77.19	63.76	8.50	2.65	-42.4	-40.8
$\text{Si}_4\text{Me}_8\text{Se}$	73.82	-	13.1	5.28	-	-41.4
$\text{Si}_5\text{Me}_{10}\text{Se}$	74.06	62.63	8.6	-2.90	-44.1	-43.3
$\text{Si}_6\text{Me}_{12}\text{Se}$	74.84	64.47	8.7	-2.18	-42.1	-40.1
$\text{Si}_4\text{Me}_8\text{NMe}$	82.56	-	9.71	1.82	-	-53.2
$\text{Si}_5\text{Me}_{10}\text{NMe}$	81.50	60.28	7.63	0.21	-48.4	-47.4
$\text{Si}_6\text{Me}_{12}\text{NMe}$	82.90	60.06	8.07	1.56	-44.9	-42.2
$\text{Si}_4\text{Me}_8\text{PMe}^a$	67.00	-	14.75	-8.27	-	-41.8
$\text{Si}_5\text{Me}_{10}\text{PMe}^a$	67.60	58.7	9.1	-16.8	-43.5	-43.0
$\text{Si}_6\text{Me}_{12}\text{PMe}^a$	69.27	-	8.85	-16.1	-42.9	-42.4

<sup>a</sup>chemical shift values are consistent with data reported in ref.[1]

NMR SPECTROSCOPY

$^{29}\text{Si}$ -NMR data of group VI heterocyclopolysilanes are summarized in TABLE 1 together with data of the corresponding N and P containing compounds<sup>3</sup>.  $^{29}\text{Si}$  chemical shift values of silicon atoms directly bonded to the heteroelements are shifted downfields with increasing electronegativity of the heteroatoms. Although there seems to be a general relationship between electronegativity and chemical shifts, the correlation is rather poor. The absolute magnitude of  $^1J_{\text{Si}(1)\text{Si}(2)}$  in permethylheterocyclopolysilanes satisfactorily can be correlated with the electronegativity of the heteroatoms (FIGURE 1).

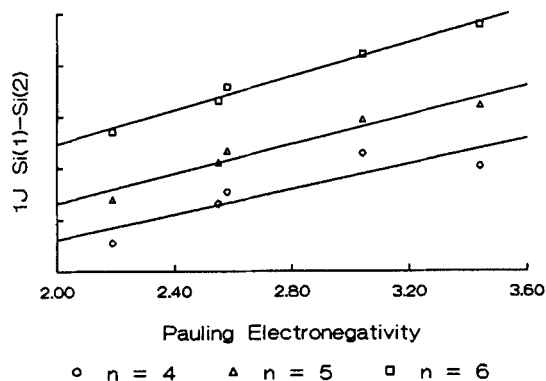


FIGURE 1    Dependence of  $^1J_{\text{Si}(1)\text{Si}(2)}$  from heteroatom electronegativity for permethylheterocyclopolysilanes  $\text{cyclo}-(\text{SiMe}_2)_n\text{X}$   
 (X = O, S, Se, NMe, PMe)

Similar correlations observed for  $^1J_{(\text{C}-\text{C})}$ ,  $^1J_{(\text{Si}-\text{C})}$  and  $^1J_{(\text{C}-\text{H})}$  in numerous systems<sup>4,5,6</sup> are usually taken to indicate the dominance of the Fermi contact contribution to spin-spin coupling. According to simple views of Fermi contact coupling the electronegative heteroatoms on Si(1) concentrate silicon s-character in hybrid orbitals directed toward Si(2) leading to higher values of  $^1J_{\text{Si}(1)\text{Si}(2)}$ . Only limited support to this crude model is given by preliminary results of semi-empirical PM3 calculations<sup>7</sup>. Linear correlations between

$^1J_{\text{Si(1)Si(2)}}$  and bond orders or silicon 3s orbital densities at Si(1) and Si(2), as suggested by equation (3), could not be obtained.

$$J_{\text{SiSi}} = \frac{16\beta^2 \gamma_{\text{Si}}^2}{9\Delta E} \cdot s_1(0)^2 s_2(0)^2 \cdot P_{\text{SiSi2}}^2 \quad (3)$$

$\Delta E$  = mean electronic excitation energy  
 $P_{\text{SiSi2}}$  = Si(1)3s-Si(2)3s bond order  
 $s_1(0), s_2(0)$  = silicon 3s orbital densities

### CONCLUSIONS

Possible explanations for the inconsistency between theory and experiments are:

1. *Insufficient theory* The simple MO approach, for instance, relating bond orders to the magnitude of coupling constants by equation (3) might not be appropriate for the compounds investigated in this study.
2. *Molecular geometry* Fully optimized geometries have been used in the PM3 calculations. Virtually conformer mixtures exist giving rise to different average charge distributions and hybridizations.
3. *Coupling mechanism* The Fermi contact term does not alone determine the magnitude of coupling constants in heterocyclopolsilanes. Possibly there are also considerable contributions from the dipolar or/and spin-orbital terms.

### REFERENCES

- 1 T.H.Newman, R.West and R.T.Oakley, J.Organomet.Chem., **197**, 159 (1980)
- 2 M.R.Detty and M.D.Seidler, J.Org.Chem., **47**, 1354 (1982)
- 3 for the synthesis of aza- and phosphacyclopolsilanes compare Lit.1
- 4 R.K.Harris and B.J.Kimber, J.Magn.Res., **17**, 174 (1975)
- 5 G.E.Maciel, J.W.McIver, N.S.Ostlund and J.A.Pople, J.Am.Chem.Soc., **92**, 1 (1970)
- 6 V.J.Bartuska and G.E.Maciel, J.Magn.Res., **5**, 211 (1971)
- 7 PM3 calculations have been performed by G.Czonka of the Techn.Univ.of Budapest. Detailed results will be published elsewhere.